MAY 2 2 2006 IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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Application Serial No	
Confirmation No	4650
Filing Date	August 31, 2000
	Vishnu K. Agarwal et al.
	Micron Technology, Inc.
	2813
Examiner	Thanh T. Nguyen
Customer No	021567
Attorney's Docket No	MI22-1518
	Enhanced Surface Area Capacitor Fabrication Methods

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

Reference - See Attached Form PTO-1449

In compliance with 37 C.F.R. §§ 1.56, 1.97 and 1.98, your attention is directed to the United States patents and other references listed on the attached Form PTO-1449. No admission is made regarding whether all the submitted references are prior art.

This Supplemental Information Disclosure Statement is being filed together with the filing of a Request for Continued Examination (RCE) Application. Therefore, no fee is believed to be required. However, in the event that a fee is required for filing this Supplemental Information Disclosure Statement, please charge the fee specified under 37 C.F.R. §1.17(p) to Deposit Account No. 23-0925. Please credit Deposit Account No. 23-0925 with any overpayment of the above fee.

Citation of these references is respectfully requested.

Respectfully submitted,

Dated: 22 May 2006

By:

James E. Lake Reg. No. 44,854 Form PTO-1449

U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE

ATTY. DOCKET NO. MI22-1518

SERIAL NO. 09/653,156

LIST OF ART CITED BY APPLICANT

(Use several sheets if necessary)

APPLICANT: Vishnu K. Agarwal et al.

FILING DATE August 31, 2000

GROUP 2813

U.S. PATENT DOCUMENTS										
*Examiner's Initials		Document . Number	Date	Name	Class	Subclass	Filing Date If Appropriate			
	AA	2002/0153579 A1	10/2002	Yamamoto						
	AB	2002/0182820 A1	12/2002	Choi et al.						
	AC	2002/0197744 A1	12/2002	Lee						
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	AF	6,849,505 B2	02/2005	Lee et al.						
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	Z.									
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	AM									
FOREIGN PATENT DOCUMENTS										
		Document Number	Date	Country	Class	Subclass	Translation			
	AN	JP 2002/222934 A	08/2002	Japan			Yes	No_		
	AO	3F 2002/222304 A	00/2002	барап						
<u> </u>										
OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)										
	АР									
	AQ									
	AR									
EXAMINER	EXAMINER DATE CONSIDERED									

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.